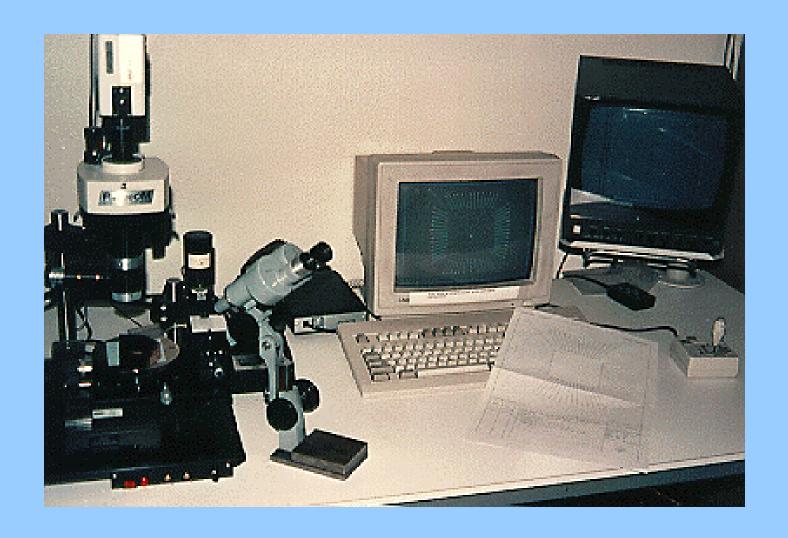
Introduction to Probe Cards

How They are Built & Tested

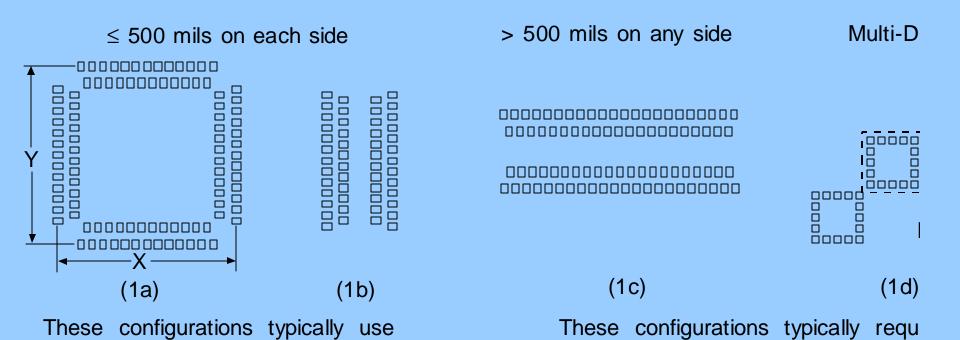
PROBE CARDS & PROCESS COURTESY OF CERPROBE



Design & Layout



DIE PAD CONFIGURATIONS



semicustom or custom rings

Figure 1: Die and Ring Configuration Examples

standard rings

Integrated Technology Corporation Copyright 1998

BONDING PADS

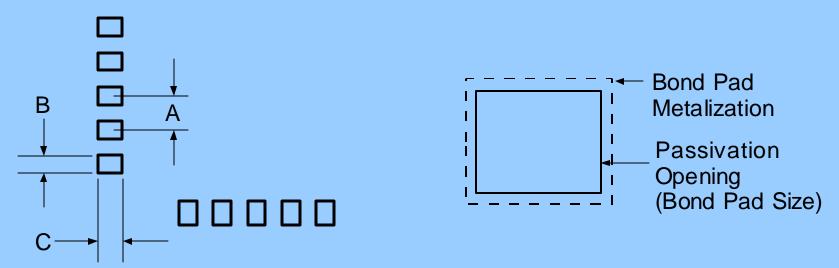


Figure 2: Bond Pad Pitch and Size

CROSS SECTION, CANTALEVER BEAM

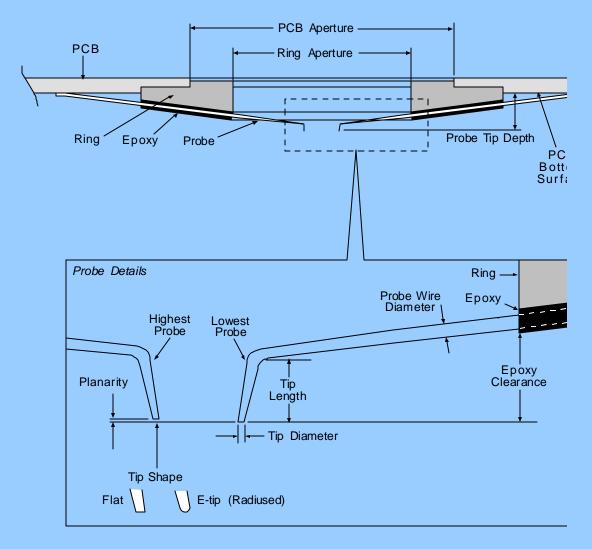


Figure 3: PCB and Epoxy Ring Assembly

EDGE SENSOR TYPES

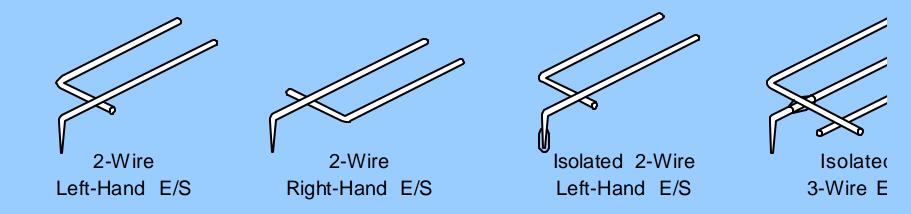
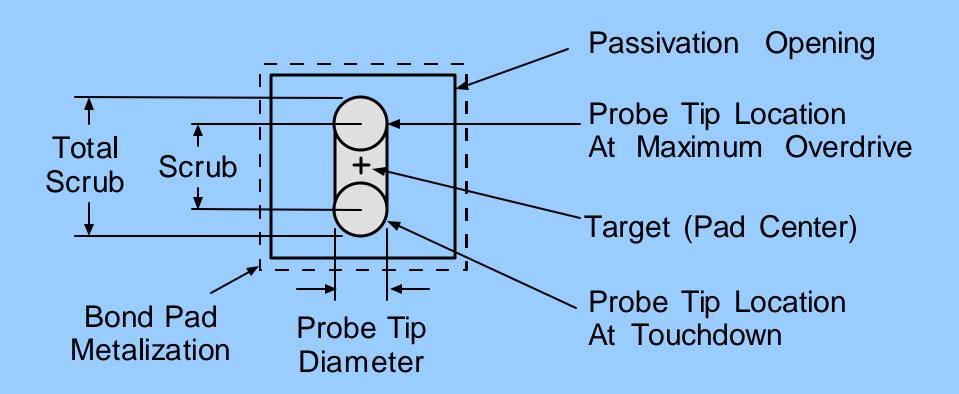
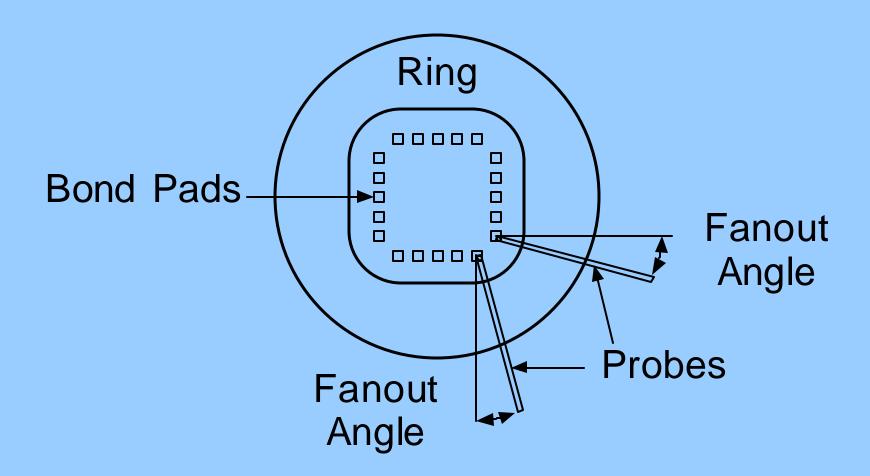


Figure 4: Edge Sensors

PROBE TO PAD POSITIONING



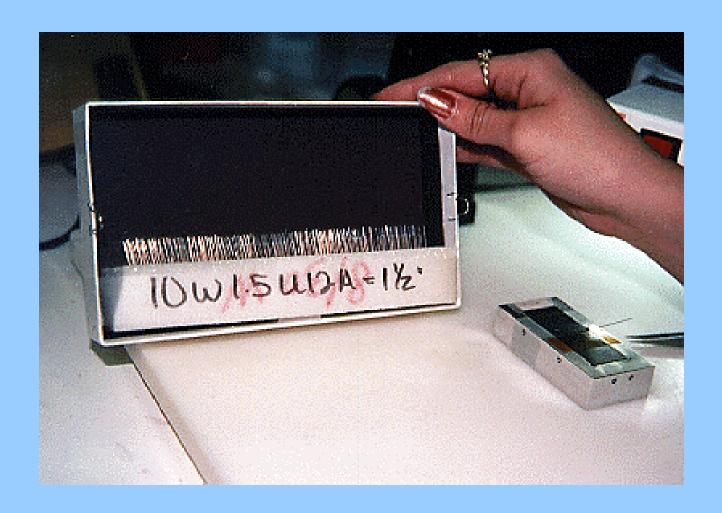
PROBE FANOUT ANGLE



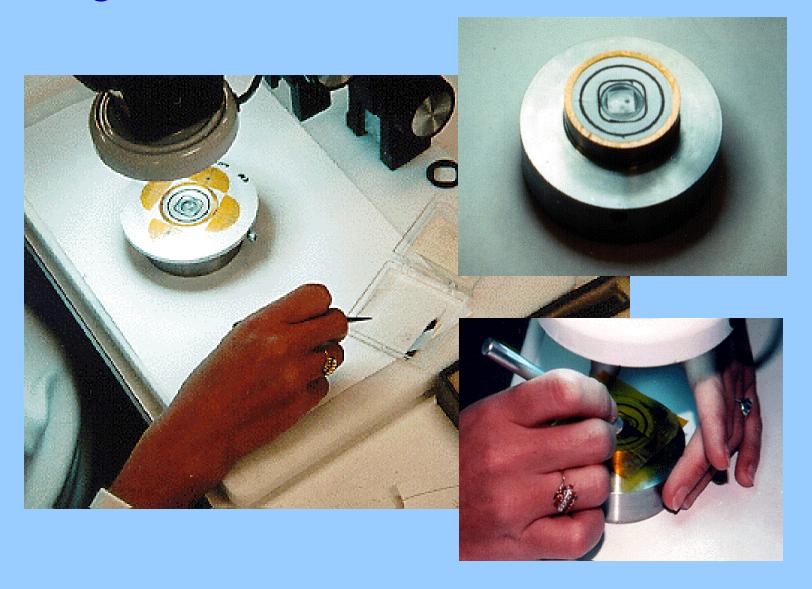
Wire Bend



Wire Bend - Replacement Probes



Ring Build & Fixture



Integrated Technology Corporation Copyright 1998

Ring Assembly



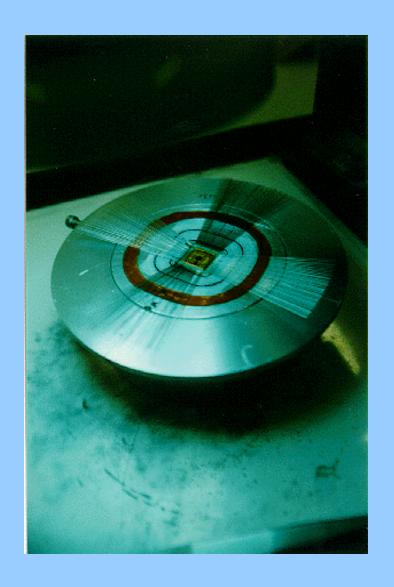




Ring Assembly

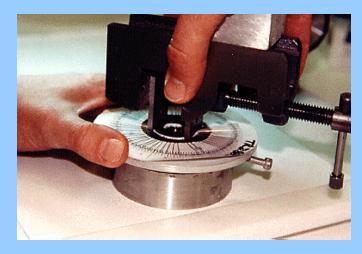


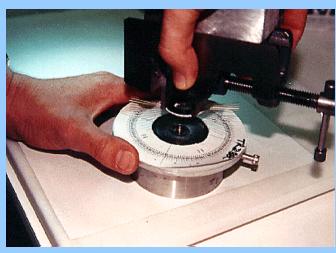


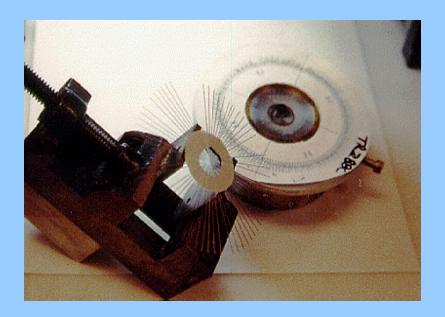


Integrated Technology Corporation Copyright 1998

Ring Removal

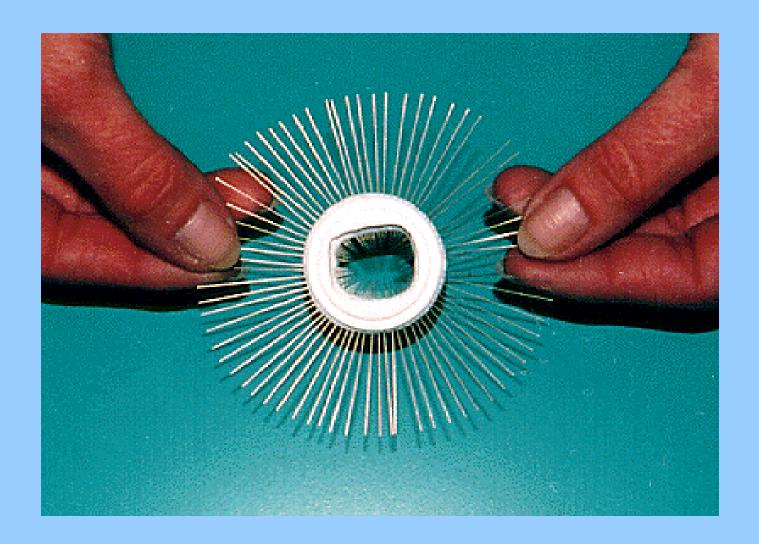




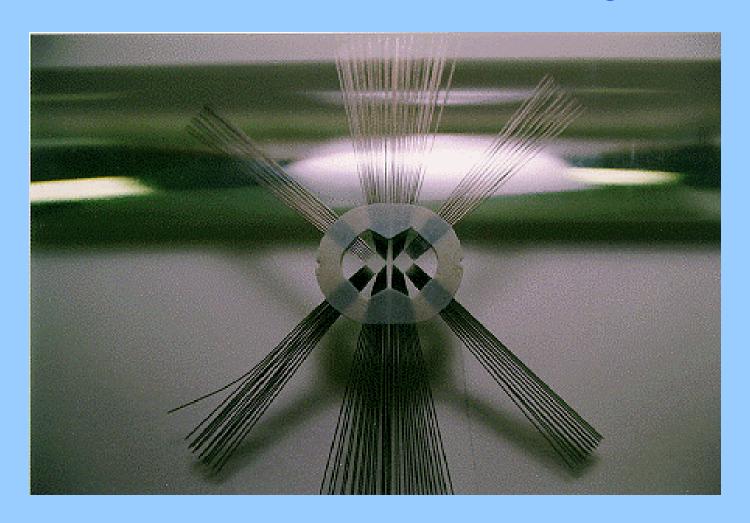


Integrated Technology Corporation Copyright 1998

COMPLETED PROBE RING



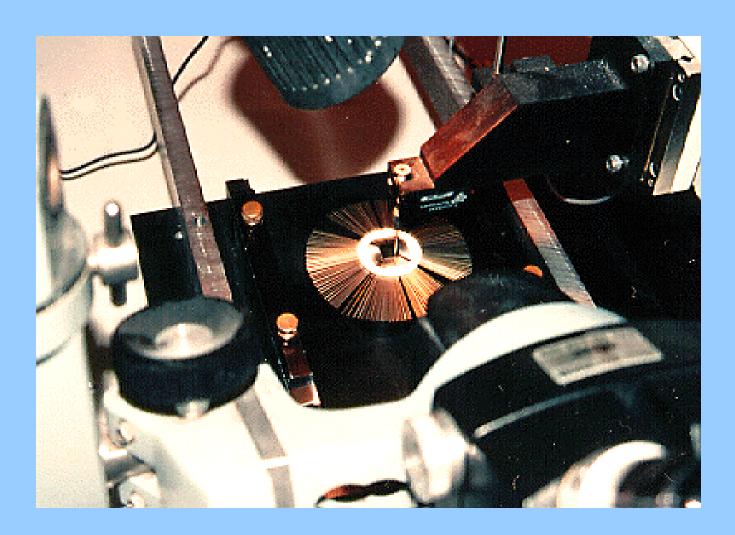
Completed Probe Ring



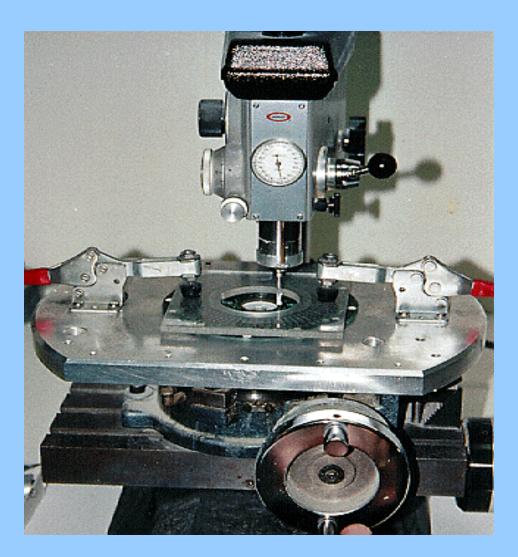
Multi Layer Ceramic Ring



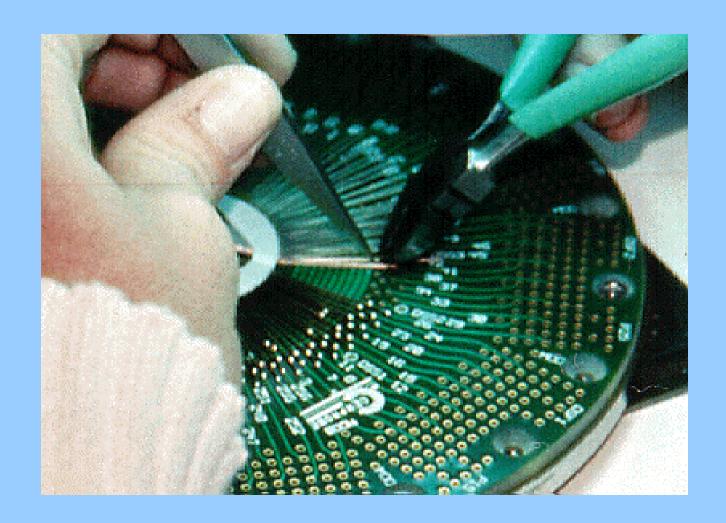
Measuring Contact Force



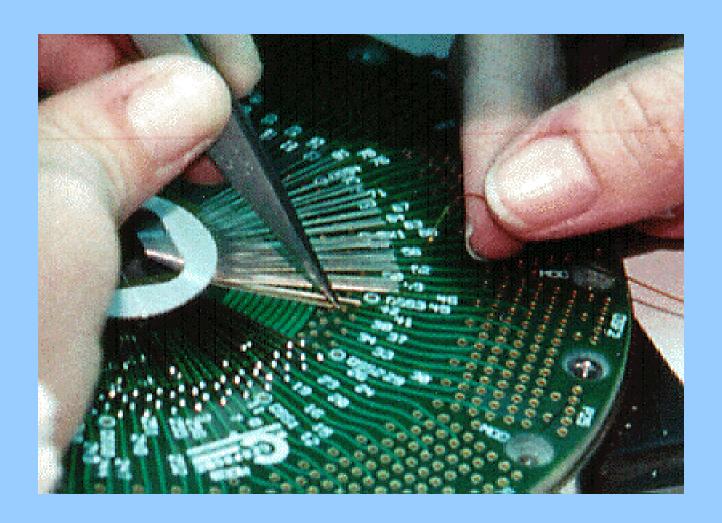
PCB Counterbore



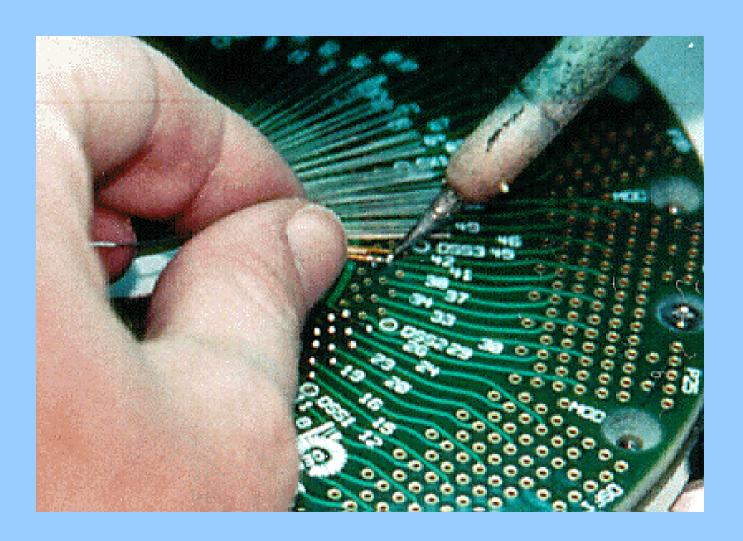
Trimming



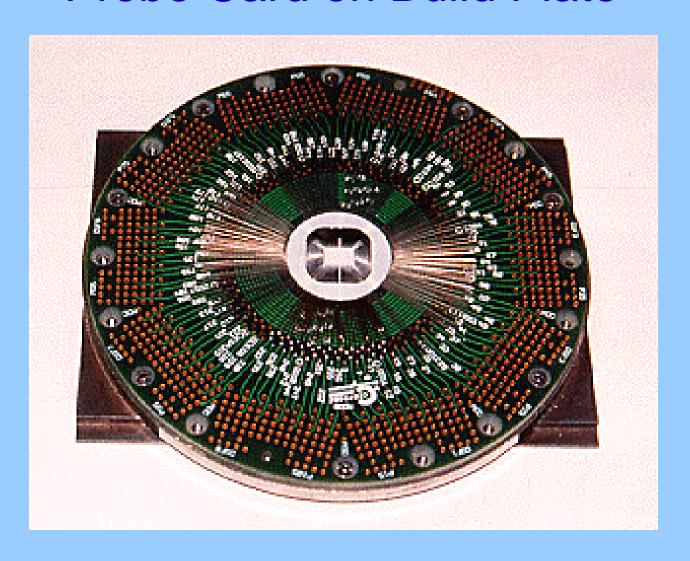
Isolative Sleeving



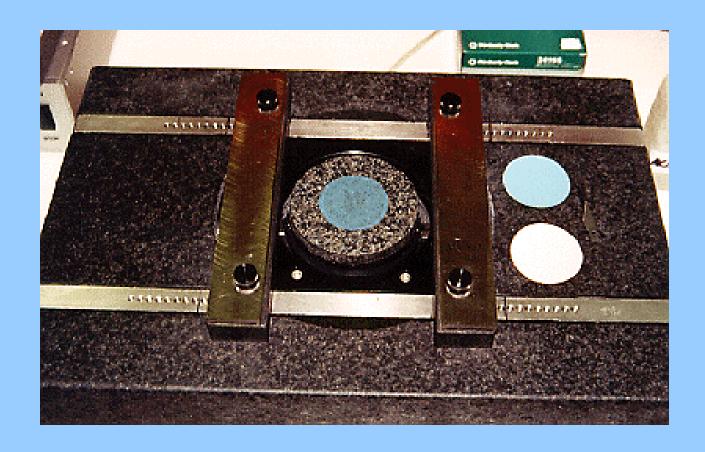
Probe Attachment



Probe Card on Build Plate



Probe Card Sanding Station



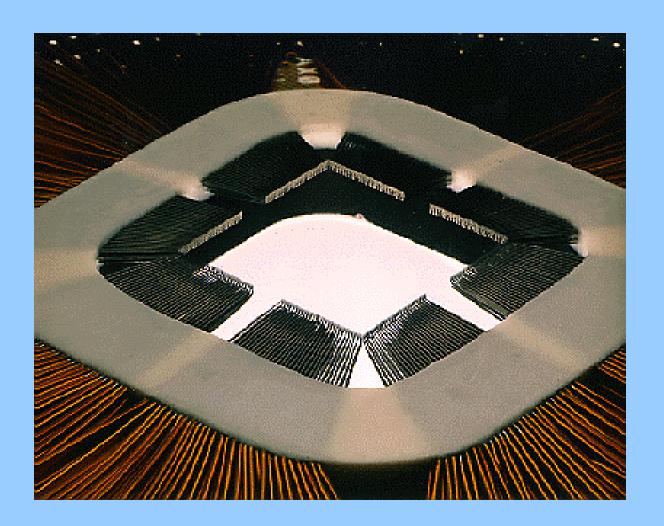
Alignment to Wafer



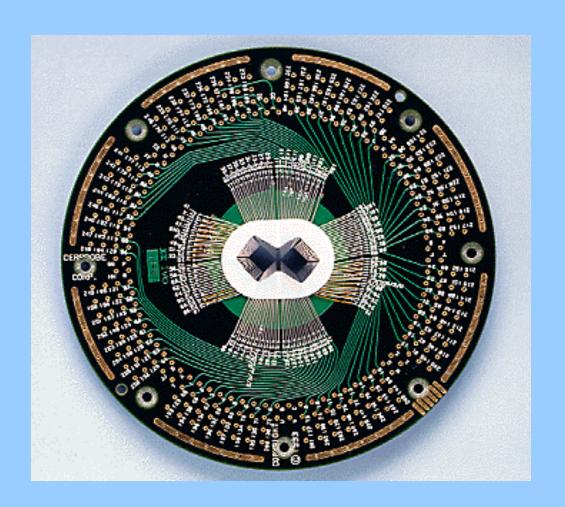
Planarization



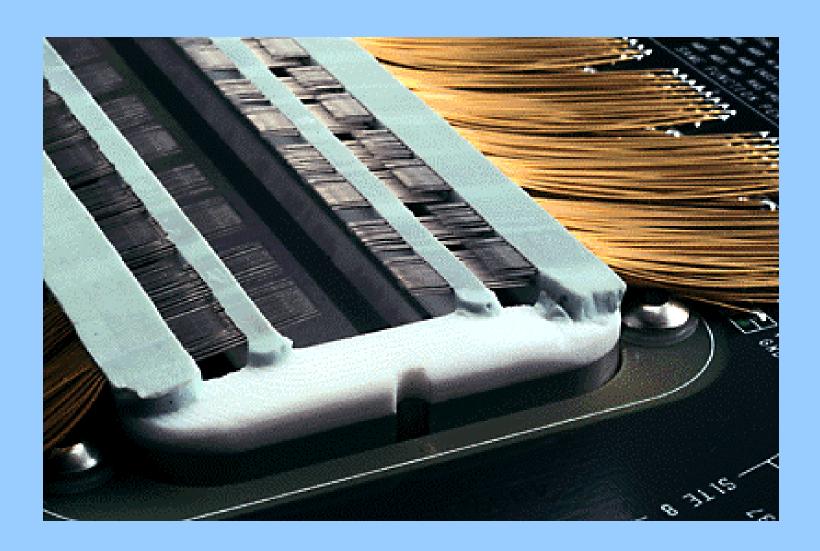
Finished Probe Card



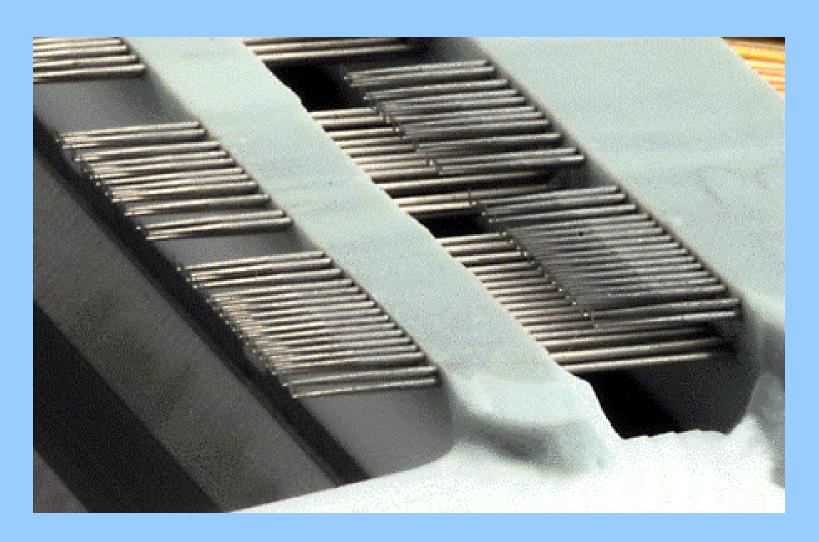
Multi-dut Probe Card



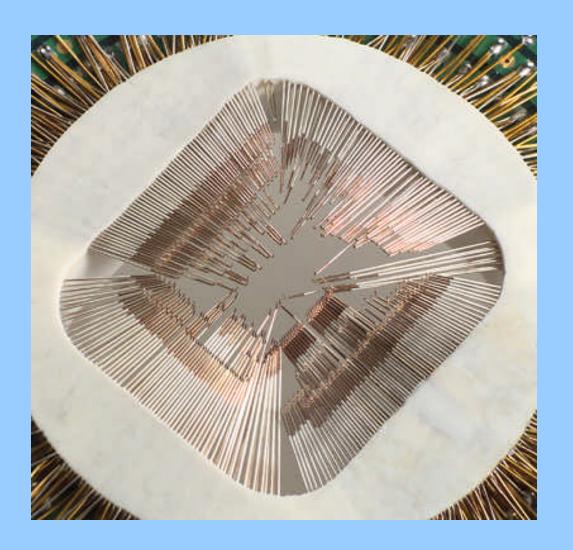
Multi-dut Probe Card



Multiple Probe Layers



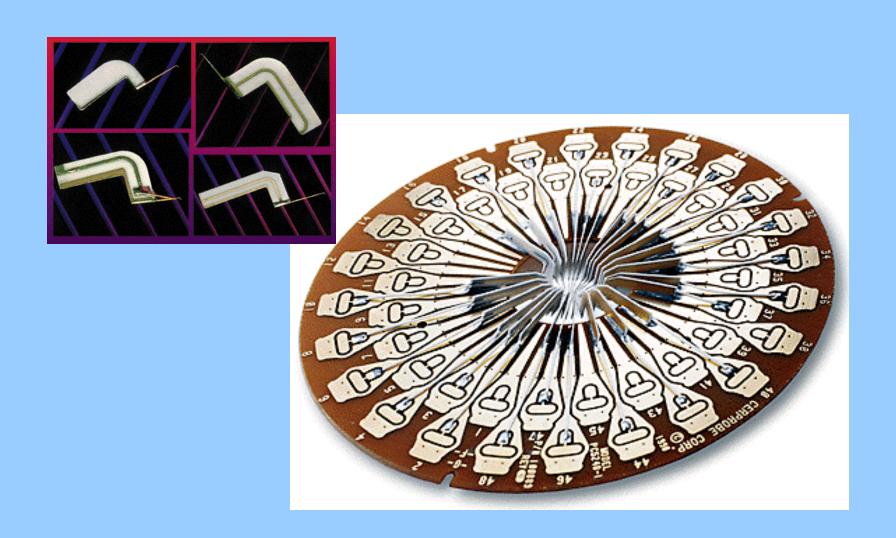
Cantilever Area Array



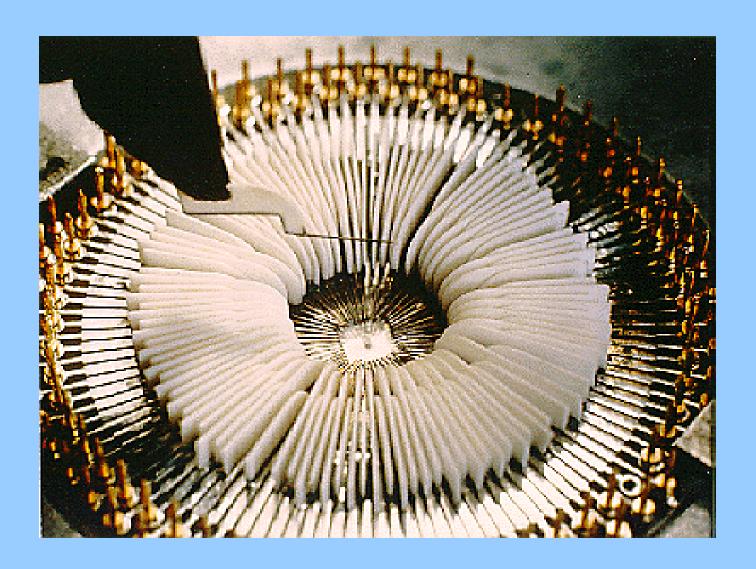
Area Array (top)



Ceramic Blade Probe Card

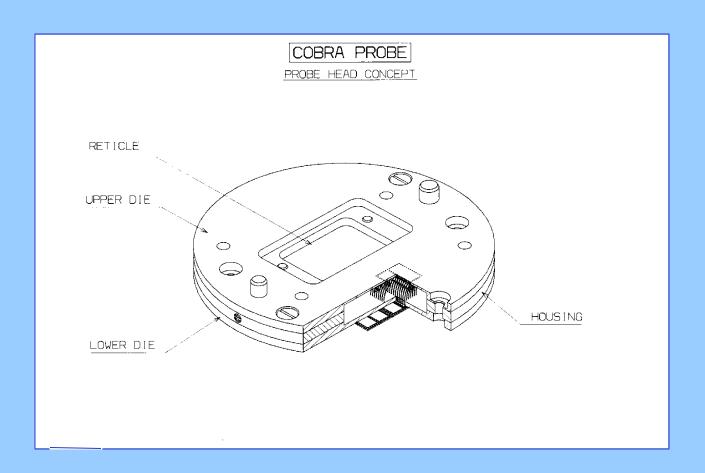


Building a Blade Card

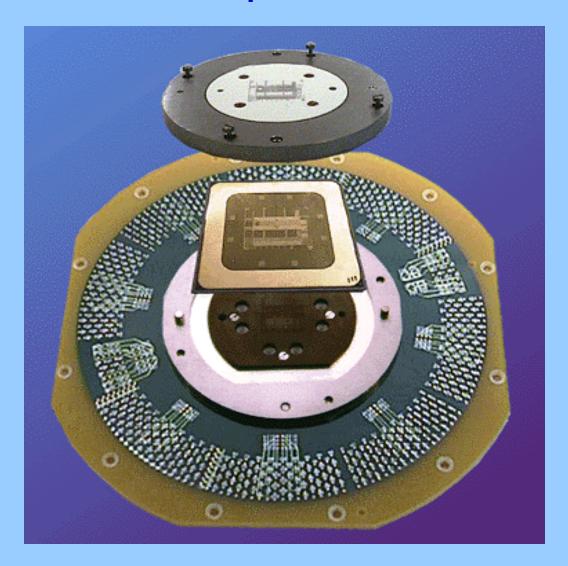


Cobra Probe Card





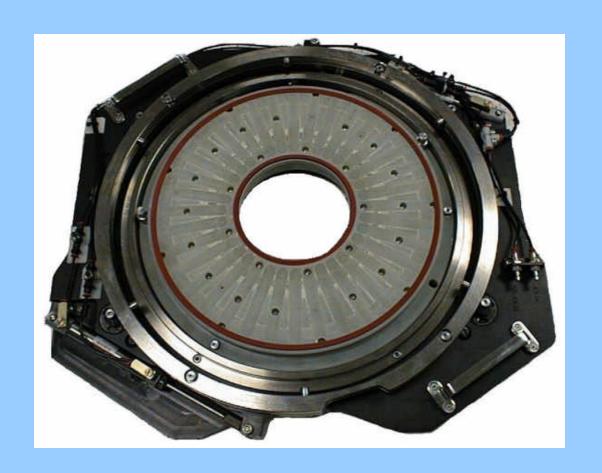
Cobra probe card



PB3000 PROBE CARD ANALYZER



PROBILT PB3000 MOTHERBOARD



PURPOSE OF TESTING

- SCREEN TO SPECIFICATION LIMITS
- ESTABLISH SPC
- ESTABLISH LIFETIME GUIDELINES
- ESTABLISH REPAIR CYCLES
- IDENTIFY POTENTIAL PROBLEMS
- IDENTIFY POTENTIAL IMPROVEMENTS

TEST PARAMETERS

ALIGNMENT TIP PLANARITY
DIAMETER

GRAM CONTACT
FORCE RESISTANCE

EXTERNAL EXTERNAL LEAKAGE

RESISTOR

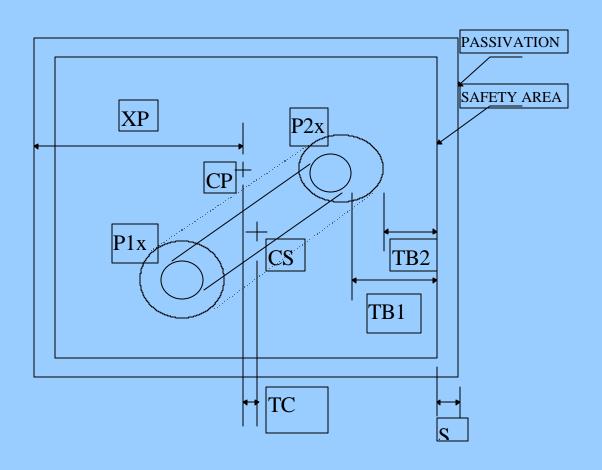
CURRENT

CAPACITOR

ALIGNMENT & TIP DIAMETER

- INSURE PAD CONTACT
- INSURE NO PASSIVATION DAMAGE
- ALLOW MAX. SET-UP TOLERANCE
- AGING MONITOR
- LIMIT FORCE/UNIT AREA

ALIGNMENT TO PAD



TIP DIAMETER

- LIFETIME INDICATOR
- "TRUE POSITION" TOLERANCING
 ELIMINATES NEED FOR MAXIMUM
 LIMIT, EXCEPT FOR EOL
- FORCE / UNIT AREA

PLANARIZATION

- INSURE GOOD CONTACT
- LIMIT SCRUB LENGTH (BENDING BEAMS)
- CONTROL SCRUB DEPTH
- LIMIT TIP FORCE

CONTACT RESISTANCE

- LIMIT RMAX FOR DC PATHS
- LIMIT SWITCHING TIME CONSTANTS
- CHECK FOR CONTAMINATION
- CHECK PATH RESISTANCE
- CR (W) TYP 300 to 500 mOHMS
- CR (BeCu) TYP 100 TO 300 mOHMS

LEAKAGE CURRENT

- ADDS TO CIRCUIT LEAKAGE
- DETECTION OF SHORTS
- AFFECTS SWITCHING TIMES
- GENERAL CONTAMINATION DETECTION

CONTACT FORCE

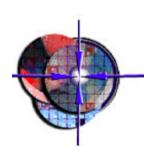
- CONTACT RESISTANCE
- SCRUB DEPTH CONTROL
- FORCE PER UNIT AREA
- GENERAL QUALITY CONTROL
- AGING MONITOR
- PROBE GEOMETRY MONITOR
- PROBE RETENTION MONITOR

COMPONENTS

- VERIFY PRESENCE/ABSENCE
- VERIFY COMPONENT VALUE
- DETECT AGING
- DETECT OTHER CHANGES

PROBER OVERDRIVE REFERENCE

- FIRST CONTACT
- EDGE SENSOR
- PROFILER
- VISUAL



Wafer Probe

Equipment

Prober

Test System

Interface

Probe Card

Wafer Handling

Product

Metalized Wafers



"Probing": Checking for the Good & Bad

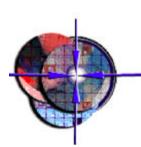
In-Process (Parametric Testing):

- When wafers are being built
- Checking for possible problems

At the End (Etest, Sorting):

- When wafers are done
- Etest checks test patterns
 - Process Parameters
- Sort identifies good/bad parts
 - Functional Test
 - Parametric Test
 - Clock Speed, Temperature, etc.





Probe Cards



Shapes

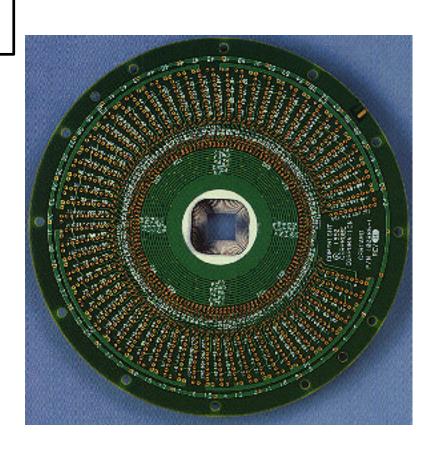
Square toRound

Sizes

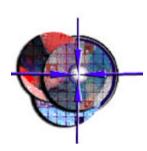
- 4" to 16"

Probe Tips

VariousMetalurgy,Types andSizes







Probe Tips



Types

- Cantilever
- Vertical
- Membrane

Size

-.8 to 4 mils

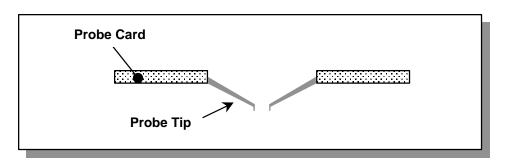
Quantity

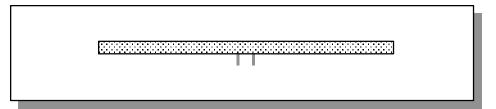
- 10 to 2000

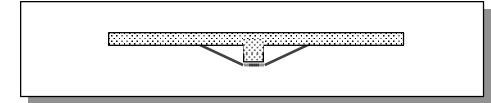
Materials

- Tungsten
- WR
- Paliney

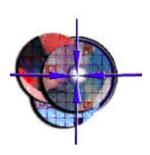












Wafer Contact Point

Chips may have Different Contact Points

Al pads

Au pads

Solder bumps

Tabs or Tape

Critical Parameters

Alignment

Contact Resistance

Pad Damage





Probe Technology Selection

Dependent on Contact Point Technology

Cantilever Beam Probes

Peripheral Pads

Al or Au Pads

Solder Bumps (Limited)

Tabs or Tape

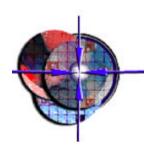
Vertical (Cobra)

Array Patterns

Solder Bumps (Flat Tips)

Al or Au Pads (Pointed Tips)





Pretty Close !!!



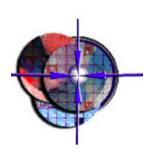
Q: How close do we need to put the probe in the pad?

A: Within +/- 10 microns in x and y directions

Q: How small is a micron?

A: If an inch was football field, a micron would be a blade of grass.





Types of Testers

Configured for Specific Technology

Memory, uProcessor, Linear, etc.

Clock Speeds >100 MHz

Rise Times <250 pS

Parallel Testing of Memory Devices (8-32 Chips)

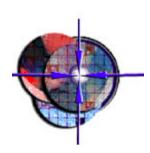
Every Interface is Different - NO STANDARDS!

Test Head Configurations

Direct Dock

Cabled





Test Head Docking

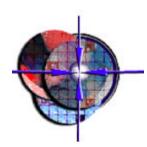
Cabled Interface

Drive/Sense Electronics in Tester Mainframe Cables (COAX or Shielded Linear) to pogos Test Interface is only pogo pins to Probe Card Slower (Clock Rate) than Direct Docking

Direct Docking

Drive/Sense Electronics in Test Head
Test Head sits Directly on the Interface
Soft or Hard Docking - Force/Weight
Highest Speeds Available

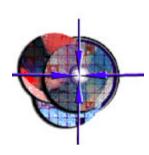




Direct Docking to Tester (Courtesy Cerprobe Corporation)



Michael George (408) 727-6500 x6244 electroglas



Wafer Handling

Loading may be Manual or Automatic Manual Loading

Use Tweezer or Vacuum Wand
Possible Damage or Breakage
Cleanliness (Particles, Contamination)
Very Slow

Automatic Loading

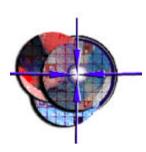
Cassette Wafer Holders

One or Multiple Cassettes

Wafer Automatically Transferred to Chuck

Faster, Cleaner, Safer

electroglas



Wafer Alignment (1)

Align Probe Tips to Pads

X,Y Position

Theta (Rotation)

Overdrive (Z Axis)

Manual Alignment

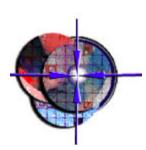
Rotate Chuck/Wafer to be on Prober X,Y Axes

Rotate Probe Card (if required)

Position Probe Tips to Touch Down on Pads

Set Overdrive to 1.0 to 4.0 mils (Type Dependent)





Wafer Alignment (2)

Automatic Alignment

Prober Aligns Wafer Using Targets
Probe Card Theta not Usually Required
Wafer Loader Aligns Wafer from Cassette
Upward Looking Camera to see Probe Tips
Downward Looking Camera to see Pads
Can Readjust Alignment During Probing

